



US00D986190S

(12) **United States Design Patent** (10) **Patent No.:** **US D986,190 S**
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(54) **CONFINEMENT PLATE FOR A SUBSTRATE PROCESSING CHAMBER**

(71) Applicant: **APPLIED MATERIALS, INC.**, Santa Clara, CA (US)

(72) Inventor: **Joseph Perry**, San Jose, CA (US)

(73) Assignee: **APPLIED MATERIALS, INC.**, Santa Clara, CA (US)

(**) Term: **15 Years**

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Related U.S. Application Data

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(51) **LOC (14) Cl.** **13-03**

(52) **U.S. Cl.**
USPC **D13/182; D15/144.1**

(58) **Field of Classification Search**
USPC D13/182, 184, 199; D15/144, 144.1, D15/144.2; 118/715; 156/345.43, 156/345.28; 216/58, 63, 67
CPC H01J 37/32623; H01J 37/32633; H01J 37/32642; H01J 37/32715; H01J 37/32733; H01J 37/32743; H01J 37/32897; H01J 37/32082; H01J 37/32091; C23F 1/00; C23F 1/10; C23F 1/12; C23F 1/14; H01L 21/00; H01L 21/67; H01L 21/67005; H01L 21/67011; H01L 21/67017; H01L 21/67063; H01L 21/67069; H01L 21/67075; H01L 21/67098; H01L 21/67115; C23C 16/00; C23C 16/458; C23C 16/44; C23C 16/04; C23C 16/4582; C23C 16/4583; C23C 16/4585

See application file for complete search history.

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Primary Examiner — Elizabeth J Oswecki

(74) *Attorney, Agent, or Firm* — Moser Taboada

(57) **CLAIM**

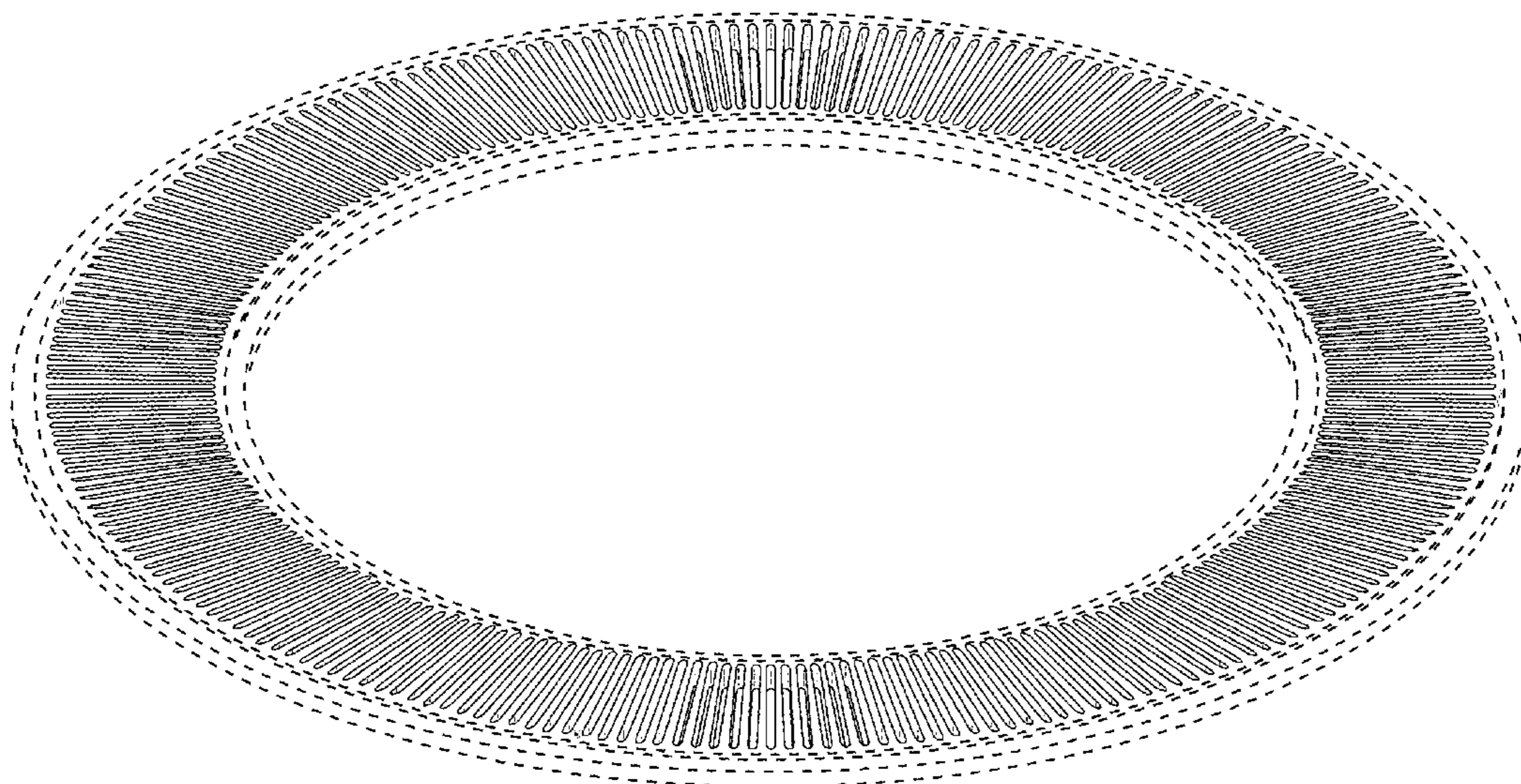
The ornamental design for a confinement plate for a substrate processing chamber, as shown and described.

DESCRIPTION

FIG. 1 is a top isometric view of a confinement plate for a substrate processing chamber, showing my new design; FIG. 2 is a top plan view thereof; FIG. 3 is a bottom plan view thereof; FIG. 4 is a front elevation view thereof; FIG. 5 is a rear elevation view thereof; FIG. 6 is a right side elevation view thereof; FIG. 7 is a left side elevation view thereof; and, FIG. 8 is an enlarged cross-sectional view taken along line 8-8 of FIG. 2.

The dashed lines in FIGS. 1-8 represent unclaimed environment forming no part of the claimed design.

1 Claim, 5 Drawing Sheets



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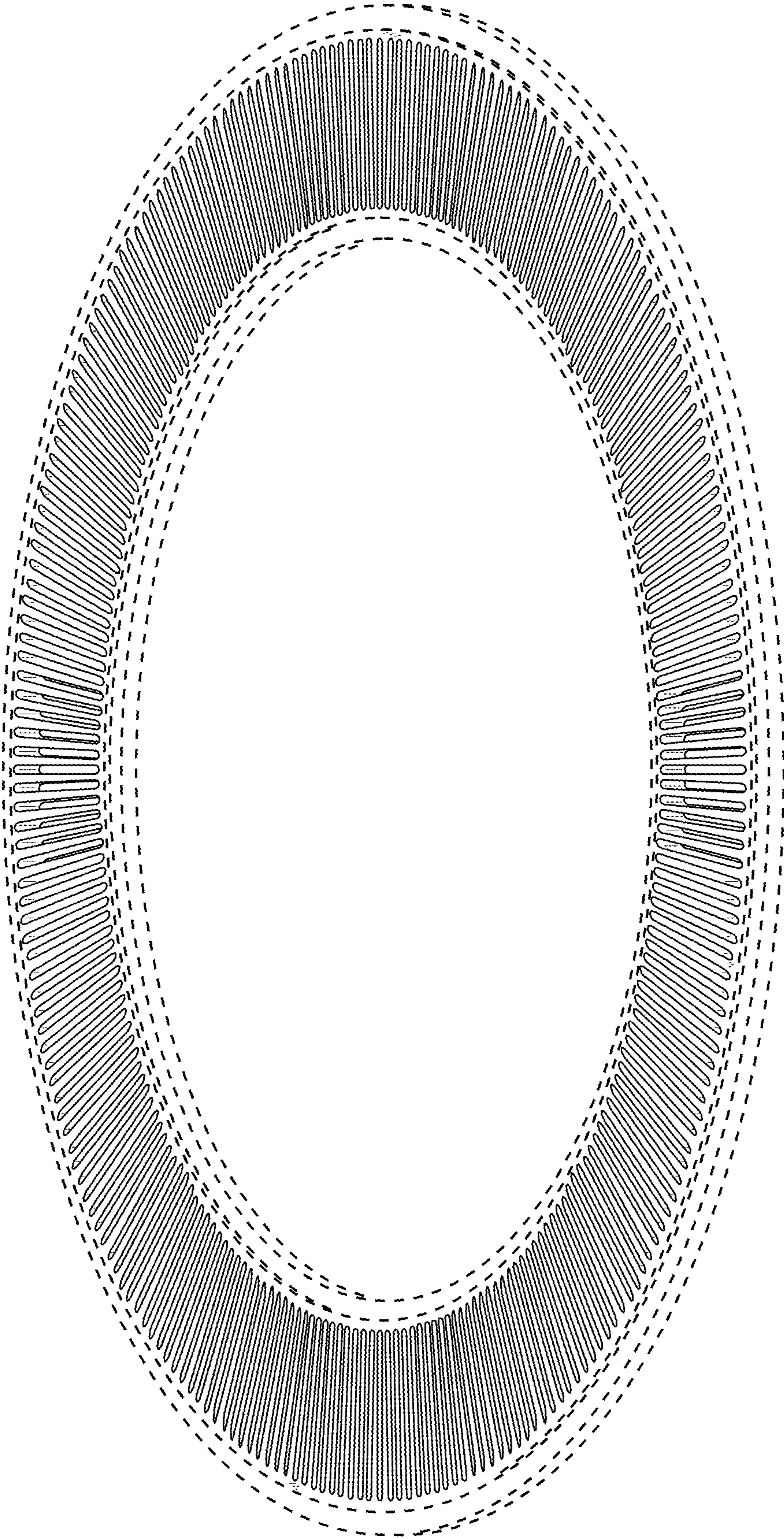


FIG. 1

FIG. 2

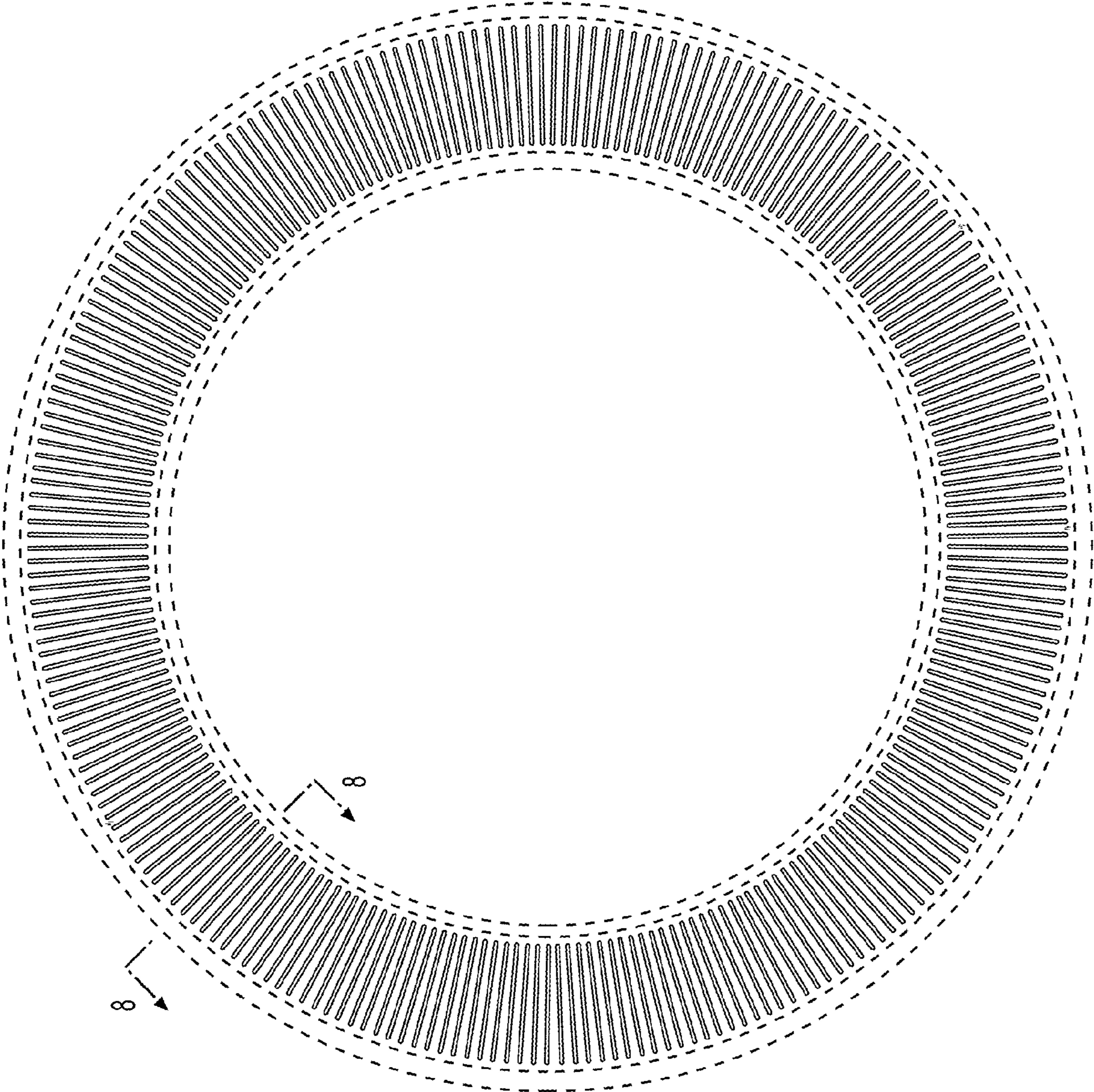


FIG. 3

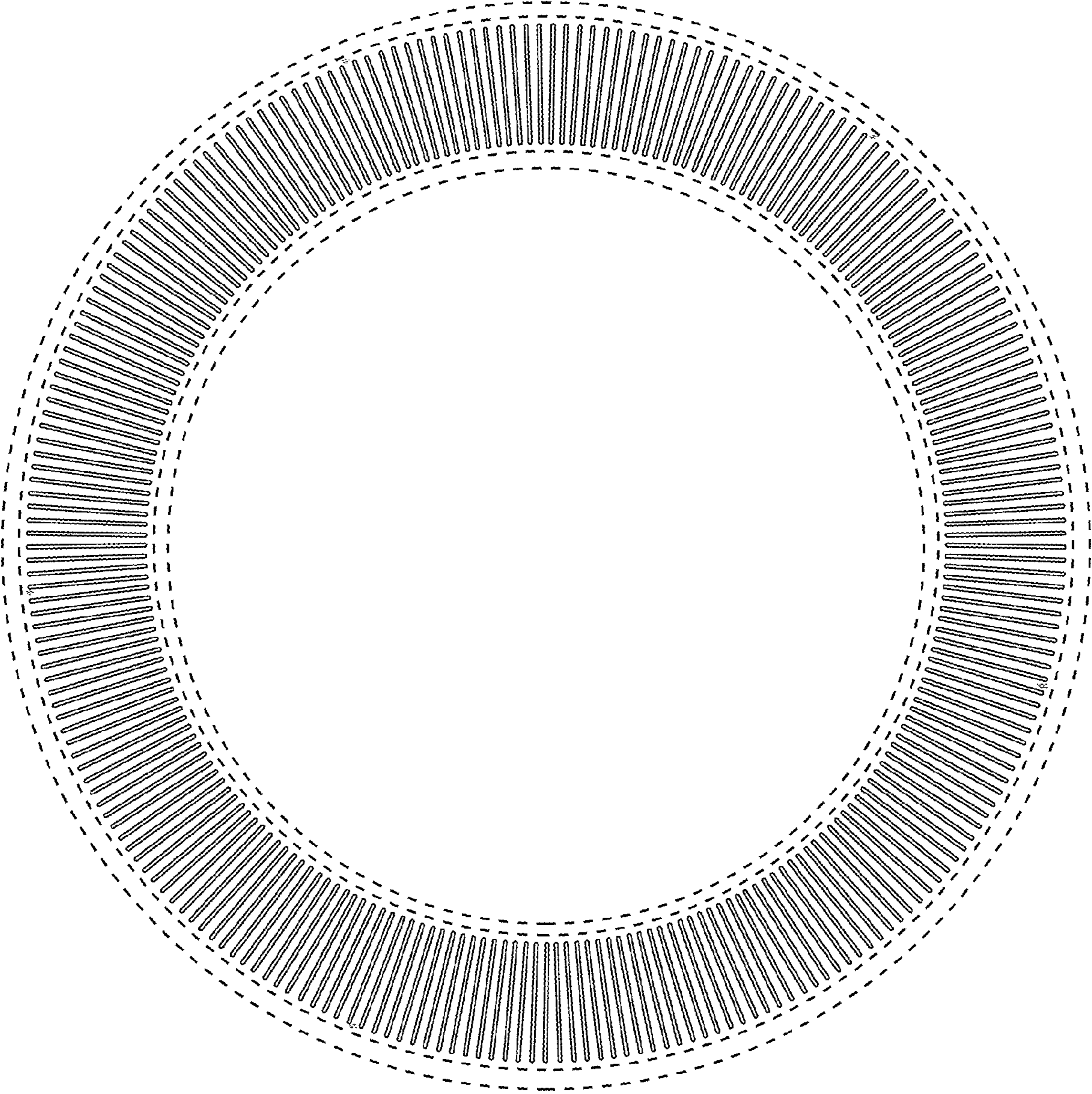




FIG. 4

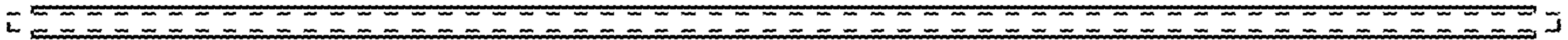


FIG. 5



FIG. 6

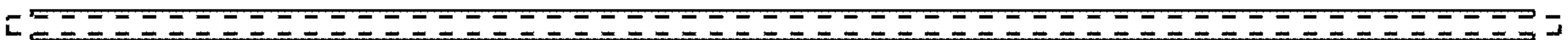


FIG. 7



FIG. 8